

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Toshihiko OHASHI et al.

Application No.: 10/541,776

Confirmation No.: 1474

Filed: July 8, 2005

Art Unit: 1771

For: SILICA-CONTAINING LAMINATED
STRUCTURE, AND COATING
COMPOSITION FOR USE IN FORMING A
POROUS SILICA LAYER

Examiner: V. S. Chang

REPLY TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the Restriction Requirement dated August 9, 2006, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

This reply includes: amendments to the specification and remarks.